

#4 Prel Amended  
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843.37558VX1

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant(s): M. FUNABASHI

Serial No.: Not Yet Assigned  
(Divisional Application of SN 09/392,568  
Filed: September 9, 1999)

Filed: July 12, 2001

For: METHOD OF MANUFACTURING A SEMICONDUCTOR  
INTEGRATED CIRCUIT DEVICE

PRELIMINARY AMENDMENT

Assistant Commissioner for Patents  
Washington, D.C. 20231

July 12, 2001

Sir:

Please amend the above-identified application, prior to  
examination thereof, as follows:

IN THE SPECIFICATION:

Please add the following new paragraph on page 1, between  
the title and the heading "BACKGROUND OF THE INVENTION":

A1 -- This application is a Divisional application of  
prior application Serial No. 09/392,568, filed September 9,  
1999. --.

Please delete the paragraph bridging pages 2 and 3, and  
substitute therefor the following new paragraph:

A2 -- Japanese Patent Application Laid-Open No. 6-41773  
discloses a technique in which an anti-adsorption agent (such  
as NTPO, EDTPO, EDDPO, or the like) is added to an aqueous  
solution containing an alkaline component such as ammonium  
hydroxide, hydroxide of alkaline metal (KOH or NaOH), choline,